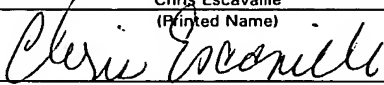
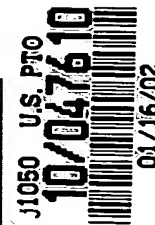


**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Babcock et al.  
Title: Phase-Shifting Mask With  
Trenches Having Multiple Depths  
Appl. No.: Unknown  
Filing Date: Unknown  
Examiner: Unknown  
Art Unit: Unknown

<b>CERTIFICATE OF EXPRESS MAILING</b> I hereby certify that this correspondence is being deposited with the United States Postal Service's "Express Mail Post Office To Addressee" service under 37 C.F.R. § 1.10 on the date indicated below and is addressed to: Commissioner for Patents, Washington, D.C. 20231.	
EL716378315US (Express Mail Label Number)	January 16, 2002 (Date of Deposit)
Chris Escaville (Printed Name)	
 (Signature)	



**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
Box PATENT APPLICATION  
Washington, D.C. 20231

Sir:

Pursuant to 37 C.F.R. §§ 1.97-98 and in accordance with the duty of disclosure under 37 C.F.R. § 1.56, Applicant submits herewith the references listed on the attached Form PTO-1449 to the Examiner such that they may be considered and made of record in the above-identified application. A copy of each reference is enclosed.

Applicant also brings to the Examiner's attention the following related application:

U.S. Appl. No. 09/776,242 entitled "Binary and Attenuating Phase-Shifting Masks for Multiple Wavelengths", filed February 2, 2001, by Ghandehari et al. (Atty. Dkt. No. 39153/328).

A copy of the application is enclosed pursuant to 37 C.F.R. § 1.98(a)(2)(iii).

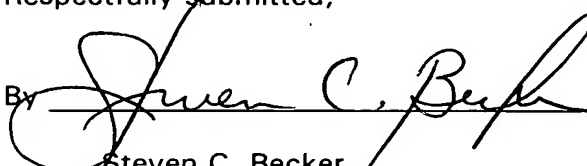
Respectfully submitted,

Date

1/16/02

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By

  
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